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Overview of the Second Order Optical Nonlinearity in GaN Waveguide for Use in Devices for Applications in Optical Communication

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Purpose: How second order nonlinearity of GaN is used in the realization of advanced optical devices in telecommunication.

Advantages of GaN:

- Supports all types of optical nonlinearity. Silicon does not have second order nonlinearity.
- GaN is CMOS compatible. Best option for both microelectronics and photonics.
- Shows ultrafast relaxation time in electro-absorption switching devices. ISB recovery time=150~400fs.
- GaN based lasers, switches, modulators, amplifiers, photodetectors are possible to materialize.
- Supports photonic integration with Silicon and Lithiun Niobate Micro-resonators.
- GaN does not suffer photorefractive effects. GaN bases optical frequency converters would not require heating during frequency conversion.

CMOS Compatibility: GaN needs to be CMOS compatible to function as both microelectronics and photonics in device development for ultrafa communication.





Fig 1. Diagram of AlGaN/GaN/AlGaN Waveguide [1]

Fig 2. GaN on silicon dioxide on silicon substrate [2]

Exploitation of Second Order Nonlinearity:

- Second order susceptibility can be achieved by breaking the symmetry of the conduction band potential.
- Large conduction band offset close to 1.8 eV in the interface of GaN/ AIN in telecommunication band.
- Utilizing ISBT and high relaxation time in QW, terahertz level optical switching is possible.
- QW shows remarkable spontaneous strained-induced piezoelectric polarization and breaks the symmetry and shows very high value of second order nonlinearity.

Implementation of Second Order Nonlinearity:

- **Modulators**
- Resonators

- Parametric Optical Amplification
- Array Waveguide grating
- Bragg reflection Waveguide
- **Optical Polarization based Logic Functions**





- Quantum Optical Applications
- Quasi-phase matching



Fig 3. Diagram of Bragg Reflection Waveguide [3]

Constraints:

- GaN is expensive compared to Silicon
- Lack of stable lattice-matched substrate
- Processing technology is not matured enough

Fig 4. (a) Capture Image of GaN microring during second harmonic generation (b) Power of the second harmonic power as a function of the pump power [4] **References:**

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Xiong, Chi, et al. "Integrated GaN photonic circuits on silicon (100) for second [2] harmonic generation." Optics express 19.11 (2011): 10462-10470.

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